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Attorney's Docket No.: 042390P11354D

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Liang, Ted et al.

Application No.: 10/659,961

Filed: September 10, 2003

For: MASK REPAIR WITH
ELECTRON BEAM-INDUCED
CHEMICAL ETCHING

Commissioner for Patents
P.O. Box 1450

FORMAL DRAWINGS SUBMISSION

Enclosed herewith for submission in the United States Patent and Trademark

Office are three (3) sheets of formal drawings for the patent application referenced

above.

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I hereby certify that this correspondence is being deposited with to sufficient postage in an envelope addressed to MAIL STOP COMMISSIONER FOR PATENTS, P.O. Box 1450, Alexandria, VA U.S. Patent and Trademark Office, Washington, D.C. 20231 onI	22313-1450
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Respectfully submitted,

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Dated: November 8, 2004

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